

# RJM0306JSP

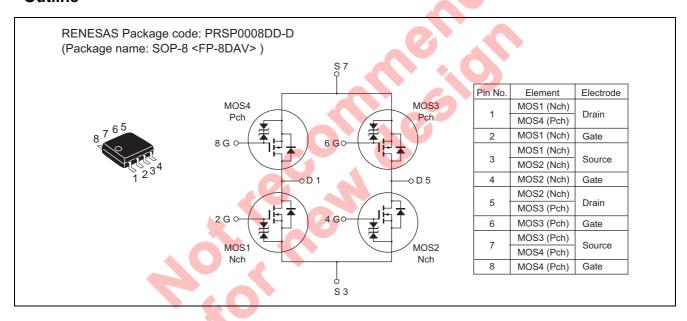
# Silicon N / P Channel Power MOS FET High Speed Power Switching

REJ03G1571-0100 Rev.1.00 Nov 16, 2007

#### **Features**

- Two elements each of N and P channels are incorporated (suitable for H-bridge circuit)
- High density mounting
- Low on-resistance
- Capable of 4 V gate drive
- High temperature D-S leakage guarantee Avalanche rating

### **Outline**



### **Absolute Maximum Ratings**

 $(Ta = 25^{\circ}C)$ 

Item	Symbol	Va	Unit	
item	Symbol	MOS1, 2 (Nch)	MOS3, 4 (Pch)	
Drain to source voltage	V <sub>DSS</sub>	30	-30	V
Gate to source voltage	V <sub>GSS</sub>	±20	±20	V
Drain current	I <sub>D</sub>	3.5	-3.5	Α
Drain peak current	I <sub>D</sub> (pulse) <sup>Note 1</sup>	28	-28	А
Avalanche current	I <sub>AP</sub> Note 4	3.5	-3.5	А
Avalanche energy	E <sub>AR</sub> Note 4	1.22	1.22	mJ
Channel dissipation	Pch <sup>Note 2</sup>	1	.5	W
Channel dissipation	Pch <sup>Note 3</sup>	2.2		W
Channel temperature	Tch	150		°C
Storage temperature	Tstg	-55 to +150		°C

Notes: 1. PW  $\leq$  10  $\mu$ s, duty cycle  $\leq$  1%

- 2. 1 Drive operation: When using the glass epoxy board (FR4  $40 \times 40 \times 1.6$  mm), PW  $\leq 10$  s
- 3. 2 Drive operation: When using the glass epoxy board (FR4  $40 \times 40 \times 1.6$  mm), PW  $\leq 10$  s
- 4. Value at Tch = 25°C, Rg  $\geq$  50  $\Omega$

# **Electrical Characteristics**

### MOS1, 2 (Nch)

 $(Ta = 25^{\circ}C)$ 

Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	V <sub>(BR)DSS</sub>	30	_	ı	V	$I_D = 10 \text{ mA}, V_{GS} = 0$
Gate to source breakdown voltage	V <sub>(BR)GSS</sub>	±20	_	1	V	$I_G = \pm 100 \ \mu A, \ V_{DS} = 0$
Zero gate voltage drain current	I <sub>DSS</sub>	_		1	μΑ	$V_{DS} = 30 \text{ V}, V_{GS} = 0$
Zero gate voltage drain current	I <sub>DSS</sub>	1	_	10	μΑ	$V_{DS} = 24 \text{ V}, V_{GS} = 0,$ $Ta = 125^{\circ}C$
Gate to source leak current	I <sub>GSS</sub>		_	±10	μΑ	$V_{GS} = \pm 16 \text{ V}, V_{DS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.0		2.5	V	$V_{DS} = 10 \text{ V}, I_{D} = 1 \text{ mA}$
Static drain to source on state resistance	R <sub>DS(on)</sub>		50	65	mΩ	$I_D = 2.0 \text{ A}^{\text{Note5}}, V_{GS} = 10 \text{ V}$
Static drain to source on state resistance	R <sub>DS(on)</sub>	_	70	105	mΩ	$I_D = 2.0 \text{ A}^{\text{Note5}}, V_{GS} = 4.5 \text{ V}$
Static drain to source on state resistance	R <sub>DS(on)</sub>	_	80	130	mΩ	$I_D = 2.0 \text{ A}^{\text{Note5}}, V_{GS} = 4.0 \text{ V}$
Input capacitance	Ciss	_	290		pF	$V_{DS} = 10 \text{ V}, V_{GS} = 0$
Output capacitance	Coss	-	85		pF	f = 1 MHz
Reverse transfer capacitance	Crss		30	\  -	pF	
Total gate charge	Qg	1	5.0		nC	$V_{DD} = 10 \text{ V}, V_{GS} = 10 \text{ V},$
Gate to source charge	Qgs	ı	1.2	}	nC	$I_D = 3.5 \text{ A}$
Gate to drain charge	Qgd		0.6	7	nC	
Turn-on delay time	t <sub>d(on)</sub>		12		ns	$V_{GS} = 10 \text{ V}, I_D = 2.0 \text{ A},$
Rise time	t <sub>r</sub>	J	12	-	ns	$V_{DD} \cong 10 \text{ V}, R_L = 5 \Omega,$
Turn-off delay time	t <sub>d(off)</sub>		35	_	ns	$R_G = 4.7 \Omega$
Fall time	t <sub>f</sub>	9- 4	8	_	ns	
Body-drain diode forward voltage	$V_{DF}$	-0	0.88	1.15	V	$I_F = 3.5 \text{ A}, V_{GS} = 0^{\text{Note5}}$
Body-drain diode reverse recovery time	t <sub>rr</sub>	7	25	_	ns	$I_F = 3.5A, V_{GS} = 0$ $di_F/dt = 100 A/\mu s$

Note: 5. Pulse test

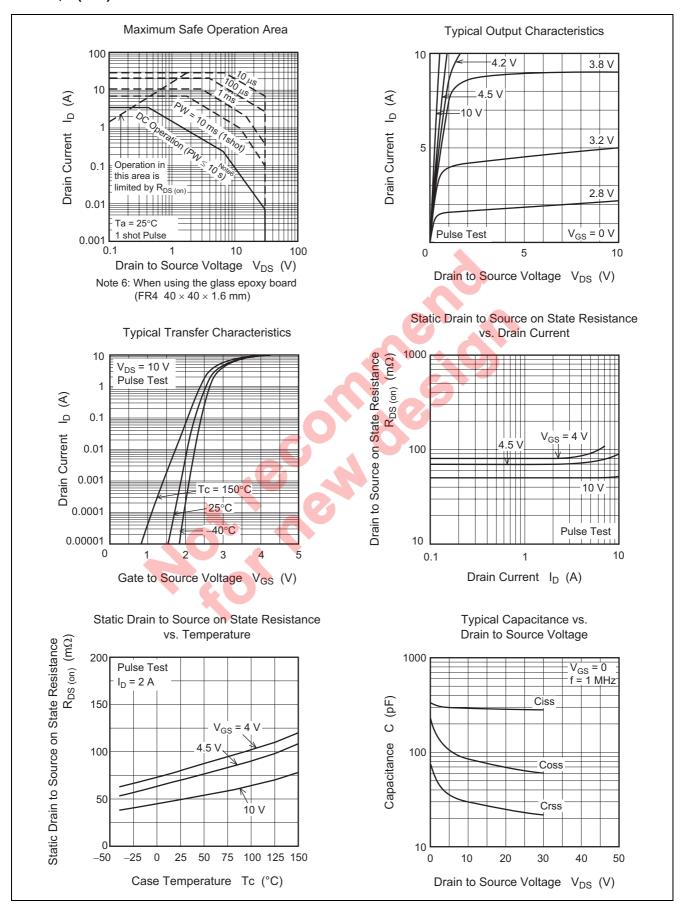
 $(Ta = 25^{\circ}C)$ 

Item	Symbol	Min	Тур	Max	Unit	Test Conditions
Drain to source breakdown voltage	V <sub>(BR)DSS</sub>	-30		_	V	$I_D = -10 \text{ mA}, V_{GS} = 0$
Gate to source breakdown voltage	$V_{(BR)GSS}$	±20	1	_	V	$I_G = \pm 100 \ \mu A, \ V_{DS} = 0$
Zero gate voltage drain current	I <sub>DSS</sub>	_	_	<b>–</b> 1	μΑ	$V_{DS} = -30 \text{ V}, V_{GS} = 0$
Zero gate voltage drain current	I <sub>DSS</sub>	1	1	-10	μΑ	$V_{DS} = -24 \text{ V}, V_{GS} = 0,$ Ta = 125°C
Gate to source leak current	$I_{GSS}$	_	_	±10	μΑ	$V_{GS} = \pm 16 \text{ V}, V_{DS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	-1.0	_	-2.5	V	$V_{DS} = -10 \text{ V}, I_{D} = -1 \text{ mA}$
Static drain to source on state resistance	R <sub>DS(on)</sub>	_	90	120	mΩ	$I_D = -2.0 \text{ A}^{\text{Note5}}, V_{GS} = -10 \text{ V}$
Static drain to source on state resistance	R <sub>DS(on)</sub>		140	210	mΩ	$I_D = -2.0 \text{ A}^{\text{Note5}}, V_{GS} = -4.5 \text{ V}$
Static drain to source on state resistance	R <sub>DS(on)</sub>		160	260	$m\Omega$	$I_D = -2.0 \text{ A}^{\text{Note5}}, V_{GS} = -4.0 \text{ V}$
Input capacitance	Ciss		320		pF	$V_{DS} = -10 \text{ V}, V_{GS} = 0,$
Output capacitance	Coss		85	_	pF	f = 1 MHz
Reverse transfer capacitance	Crss		50	-	pF	
Total gate charge	Qg		6.0		nC	$V_{DD} = -10 \text{ V}, V_{GS} = -10 \text{ V},$
Gate to source charge	Qgs		1.4	_	nC	$I_D = -3.5 \text{ A}$
Gate to drain charge	Qgd		1.0		nC	
Turn-on delay time	$t_{d(on)}$		30		ns	$V_{GS} = -10 \text{ V}, I_{D} = -2.0 \text{ A},$
Rise time	t <sub>r</sub>	_	17	4	ns	$V_{DD} \cong -10 \text{ V}, R_L = 5.0 \Omega,$
Turn-off delay time	$t_{\text{d(off)}}$		30		ns	$R_G = 4.7 \Omega$
Fall time	t <sub>f</sub>		7		ns	
Body-drain diode forward voltage	$V_{DF}$		-0.92	-1.2	V	$I_F = -3.5 \text{ A}, V_{GS} = 0^{\text{Note5}}$
Body-drain diode reverse recovery time	t <sub>rr</sub>		30	_	ns	$I_F = -3.5 \text{ A}, V_{GS} = 0$ $di_F/dt = 100 \text{ A}/\mu\text{s}$

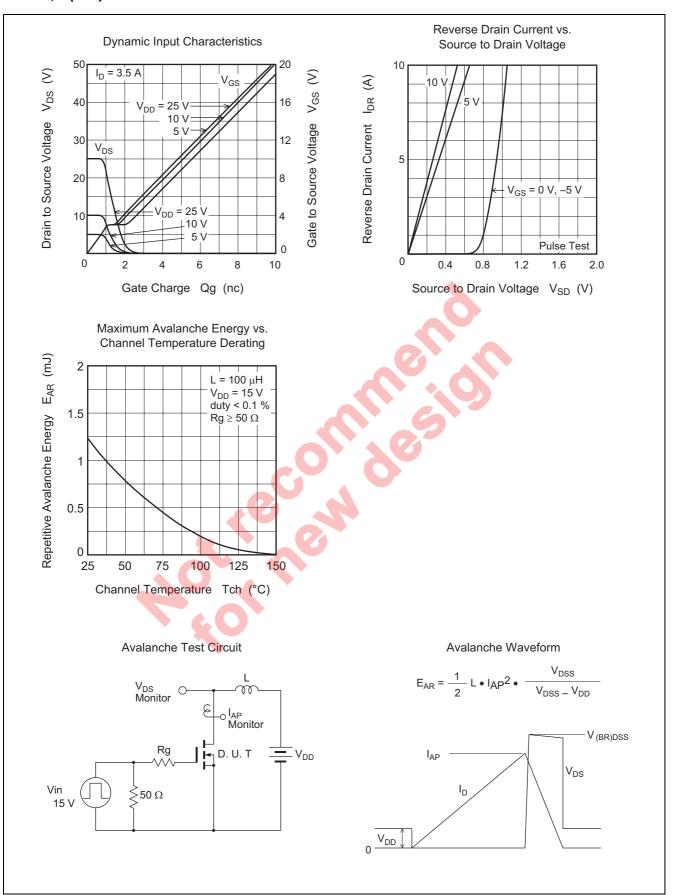
Note: 5. Pulse test

#### **Main Characteristics**

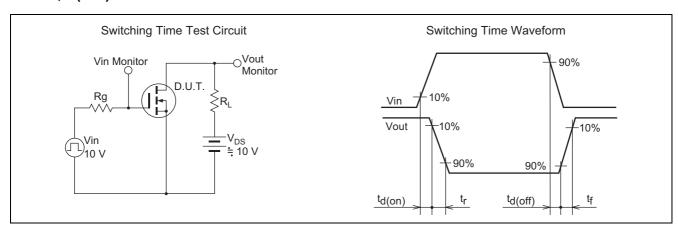
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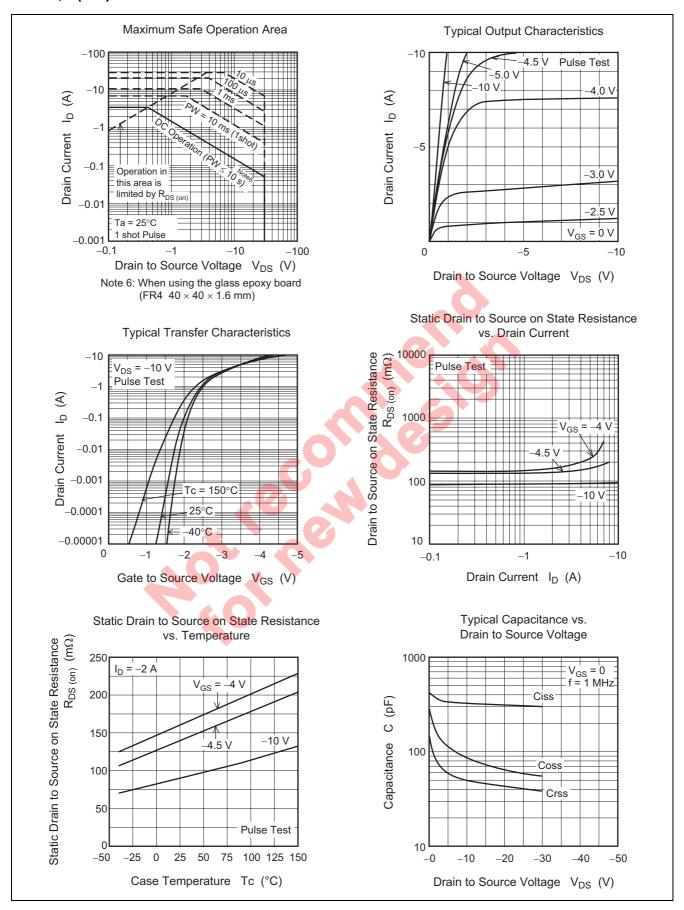
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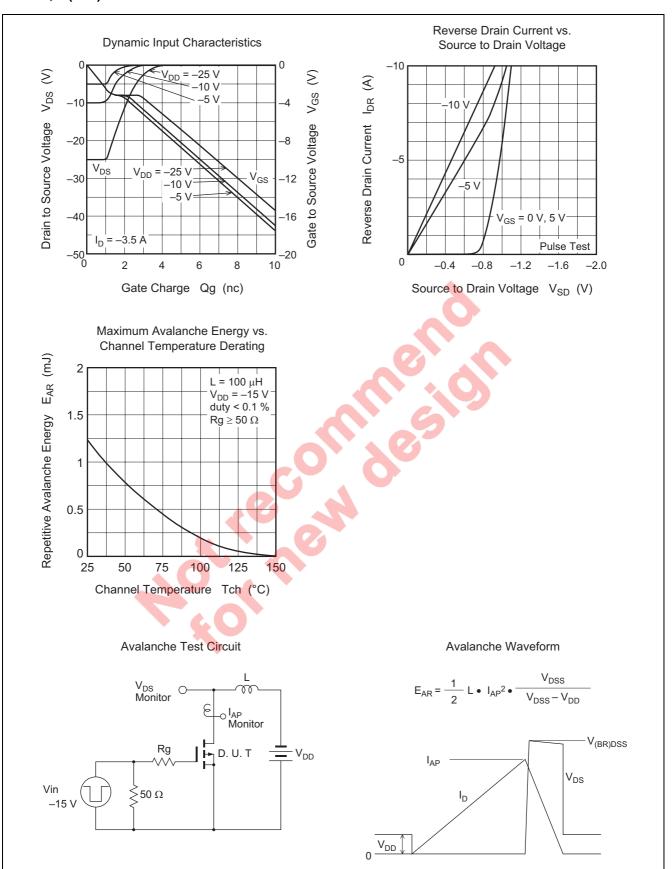


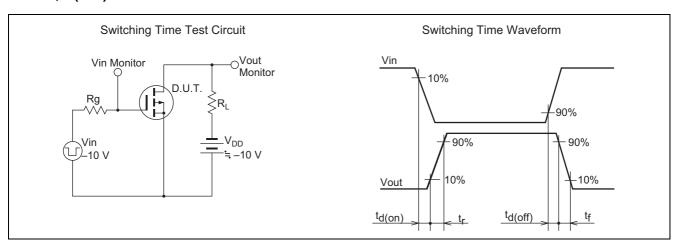
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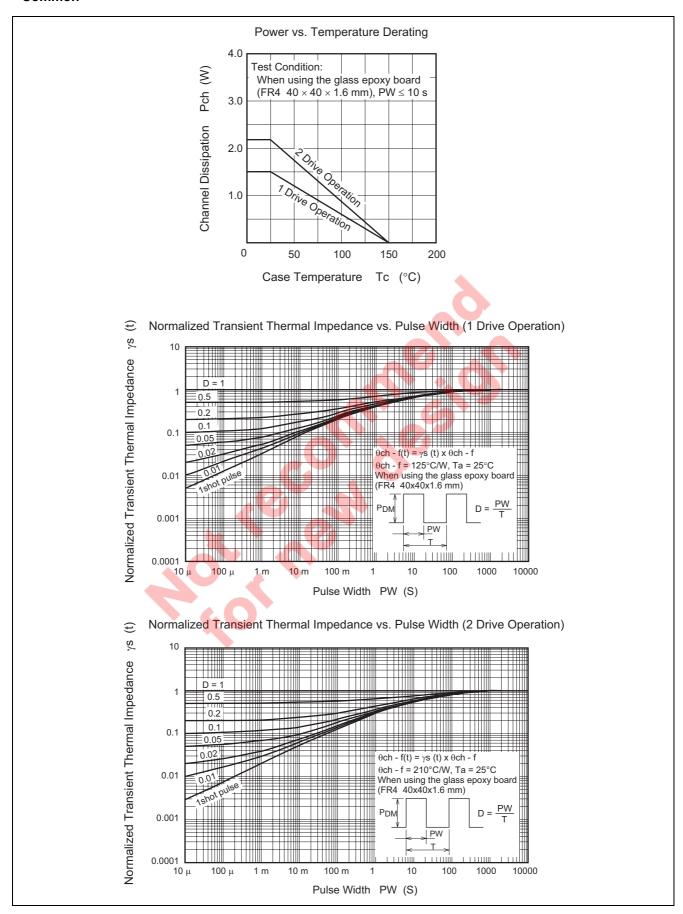




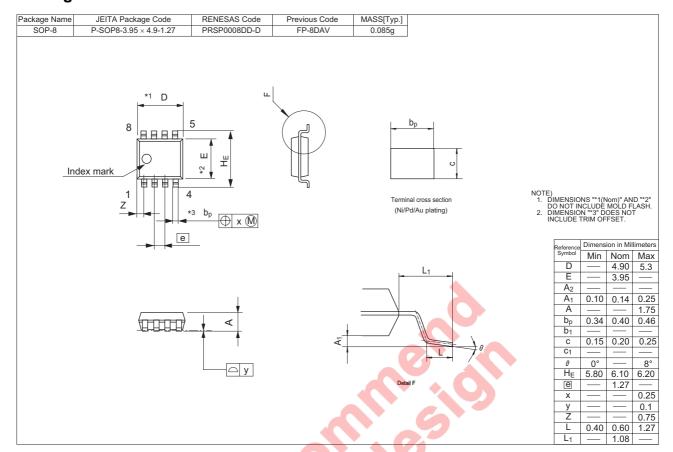




#### Common



### **Package Dimensions**



# **Ordering Information**

Part No.	Quantity	Shipping Container
RJM0306JSP-00-J0	2500 pcs	Taping

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